

MOSFET Regions

Electrical Engineering

Cut-off, ohmic and saturation for a field-effect device, and the naming trap.

A MOSFET is off below threshold, resistive while V_{DS} is small, and a current source past pinch-off.

$V_{ov} = V_{GS} - V_{th}$ · Saturated: $I_D = \frac{1}{2}k V_{ov}^2$

V_{GS} below V_{th}

Leakage only.

Cut-off

V_{DS} under V_{ov}

Switch region.

Ohmic, $R_{DS(on)}$

V_{DS} over V_{ov}

Amplifier region.

I_D set by V_{GS}

THE COMMON MISTAKE

× Driving a standard MOSFET from 3.3 V logic

✓ Reading $R_{DS(on)}$ at the gate voltage available

$R_{DS(on)}$ is quoted at 10 V of gate drive. At 3.3 V a standard part is barely on, and it overheats as a switch.

Naming trap: a bipolar transistor saturates when fully on, a MOSFET when acting as a current source. Opposite ends.